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Optimization of mechanical and dielectric properties of poly(urethane–urea)-based dielectric elastomers *via* the control of microstructure†

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In this work, we fabricated novel poly(urethane–urea) (PUU)-based dielectric elastomers using a hydroxyl-terminated butadiene–acrylonitrile copolymer (HTBN) as the soft segment and hexamethylene diisocyanate (HDI) and 3,3'-dimethyl-4,4'-diamino dicyclohexyl methane (DMDC) as hard segments. The effect of hard segment (HS) content on the hard domain (HD) structure, morphology, dielectric and mechanical properties was investigated with Fourier transform infrared spectroscopy (FTIR), small/wide angle X-ray scattering (SAXS/WAXS), broadband dielectric spectroscopy and mechanical testing methods. Our results indicated that the hard domain structure units of PUUs such as degree of hydrogen bonding, size and crystallinity played an important role in the dielectric and mechanical properties. The dielectric constant of PUUs was significantly decreased with increasing HS content, whereas the breakdown strength and Young's modulus of PUUs were significantly increased. The relationship between multi-length scale structure and dielectric constant and breakdown strength properties of PUUEs were discussed. Our results can provide a new insight for optimization of dielectric and mechanical properties of PUU-based dielectric elastomers.

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1. Introduction

Among the electroactive polymer materials, dielectric elastomers (DEs) are recognized as a most promising artificial muscle candidate due to their large actuation strain, high energy density, marvelous flexibility, light weight, easy processing, and low cost.¹ Accordingly, many researchers have made great efforts to improve the electromechanical properties of DEs to mimic fully the nature of muscle to generate large strokes (~20%), respond and recover rapidly (less than 1 s), and provide billions of work cycles (peak at around 10⁹) with large energy densities (around 150 J kg^{−1}).^{1–3} However, how to realize a large strain under a low driven voltage is still a great challenge in developing ideal DEs to fully mimic human muscles. Enhancing the dielectric constant and/or decreasing modulus of DEs is an effective way to improve the electro-actuation properties of DEs.

In addition, the electrical breakdown strength of DEs which is influenced by microstructure and impurities of materials is also an essential factor to influence the maximum actuation strain. These factors should be carefully considered in designing novel DEs with improved electromechanical actuation performance.

Various types of soft materials, including acrylic elastomers,⁴ polyurethanes (PUs),⁵ silicone rubbers (SRs)^{6–9} and polystyrene-*co*-ethylene-*co*-butylene-*co*-styrene triblock copolymers (SEBS)^{10,11} have been investigated as DEs to obtain artificial muscles with high electromechanical performances. Among them, acrylic elastomers (typical commercially available 3M VHBTM) are the first and commercially available materials that have been widely investigated for electromechanical actuators.^{12,13} However, there are some issues limiting the wide application of 3M elastomers in DE actuators, such as large viscoelasticity, high sensitivity to temperature and humidity, and slow creep recovery, although a very large actuation strain of over 380% can be achieved.^{12,13} Recently, chemical modification approaches have been utilized in all-organic based DEs to improve the electromechanical properties. For example, Madsen *et al.*¹⁴ prepared a new high dielectric permittivity elastomer system through the use of dipolar siloxane copolymers. The elastomer films with dipolar siloxane copolymers showed higher dielectric constant (3.3–8.5@1 kHz), higher breakdown strength (60.5–81.1 kV mm^{−1}) and higher conductivity (10^{−12}–10^{−10} S cm^{−1} order at 0.1 to 10⁴ Hz of frequency) than the polydimethylsiloxane (PDMS) reference (3.0@1 kHz,

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55.4 kV mm⁻¹ and 10⁻¹⁴ to 10⁻¹² S cm⁻¹ order at 0.1 to 10⁴ Hz of frequency). But meanwhile, the introduction of dipolar siloxane copolymers caused significantly increased of dissipation factor (0.01–0.90@1 kHz) and stiffness. Zhang *et al.*⁷ synthesized azobenzenes with strong permanent dipole moments to co-crosslink with hydroxyl-terminated polydimethylsiloxane through a simple one-step process. The dielectric constant of azo-*g*-PDMS films at 1 kHz increased from 2.72 to 4.88 with the increase of azobenzene contents. By grafting with 4.0 wt% of azobenzene, the breakdown strength of azo-*g*-PDMS reached 89.4 kV mm⁻¹, which is 36% higher than that of pristine silicone rubber. The azo-*g*-PDMS film with 7.1 wt% of azobenzenes displayed a maximum area strain of 17%. More recently, Ma *et al.*¹⁵ designed and synthesized a series of symmetric poly(styrene-*b*-butyl acrylate-*b*-styrene) (SBAS) dielectric elastomers using reversible addition-fragmentation transfer (RAFT) polymerization method. All SBAS copolymers showed low modulus (<1 MPa), high break elongation (over 900%), high static maximum area strain (>60%) and high breakdown strength (100–250 kV mm⁻¹) that comparable with silicone elastomers. And compared to well-accepted VHBTM acrylic elastomer and silicone elastomers, all SBAS copolymers showed higher dielectric constant (above 4.5@10³ Hz). Even through many researchers have been achieved high dielectric constant and breakdown strength *via* chemical modifications, the relationship between multi-phased structure and dielectric property has been less reported so far.

Polyurethane elastomer (PUE) is a multi-block copolymer which is composed of soft and hard segments (HS and SS). The hard and soft segments of PUEs can be separated to form few tens nanometer length scale of hard and soft domains, respectively. The mechanical and physical properties of PUE are strongly dependent on their microphase separated microstructure. In addition, the PUEs have many advantages such as easy controllable structure, good biocompatibility, mechanical, dielectric properties and processability.¹⁶ Among the strategies for improving the dielectric constant and breakdown strength, the method of adjusting the microstructure *via* chemical structure design is an effective way to achieve higher performance. For example, more recently, we demonstrated that the polyurethane elastomers with high dielectric constant (>7.6 at 1 kHz) and lower dielectric loss (<0.077 at 1 kHz) can be achieved using hydroxyl-terminated butadiene-acrylonitrile copolymer (HTBN) as soft segment.¹⁷ And, we found that the dielectric constant and breakdown strength of PUEs are strongly dependent on their hard domain structure and morphology.¹⁸ In contrast with PUEs, the PUUEs have both urethane and urea units in their hard segments. Accordingly, the effects of hard domains (HDs) on dielectric and mechanical properties of PUUEs may be different with PUEs due to different hydrogen bonding behaviors of HSs.

In addition, even though many literature investigated the dielectric properties of PU/PUUs,^{19–24} the effects of microstructure of PUUEs on dielectric and mechanical properties still have less been understood, so far. For example, how the hydrogen bonding structure and crystallinity of hard domains and microphase separated network structures contribute to the

dielectric constant, dielectric loss and breakdown strength of PUUs?

In this work, we fabricated novel poly(urethane-urea) (PUU)-based DEs using hexamethylene diisocyanate (HDI) and 3,3'-dimethyl-4,4'-diamino dicyclohexyl methane (DMDC) as hard segment and HTBN as soft segment. The effect of HS content on structure, mechanical and dielectric properties of PUUEs were investigated in detail.

2. Experimental

2.1 Materials

Hydroxyl-terminated polybutadiene-acrylonitrile copolymer (HTBN) which has 13.9 wt% of cyano content and 0.6149 mmol g⁻¹ of hydroxyl value was supplied by Zibo Qilong Chemical Industry Co. Ltd., in China. The average molecular weight of HTBN is 3500 g mol⁻¹. Hexamethylene diisocyanate (HDI, purity 99%) was purchased from Aladdin Industrial Co. Ltd. 3,3'-dimethyl-4,4'-diamino dicyclohexyl methane (DMDC) with 9.5365 mmol KOH per g of amine values was purchased from Shenzhen Yexu Industry Co. LTD, in China. *N,N*-Dimethylformamide (DMF) was purchased from Beijing Tongguang Fine Chemical Industry Co., China. The DMDC and DMF were treated by the 4A type molecular sieve (Tianjin Fuchen Chemical Reagents Factory) for removing the residual waters before used. The chemical structures of raw materials are shown as Table 1.

2.2 Synthesis of poly(urethane-urea) elastomers

PUUEs were synthesized by two-step polymerization method.¹⁷ In the first step, the HTBN was degassed at 110 °C for 3 h in order to remove the moistures from HTBN in the four-necked flask before polymerization. After degassing, the temperature reduced to 70 °C, following added HDI and purged dry nitrogen gas into flask to react for about 2–3 hours. After completion of pre-polymerization, the temperature reduced to room temperature and then added DMF and previously dissolved DMF of DMDC into flask, and then raised up to 60 °C to react for about 2–3 hours.

The concentration of the reaction mixture in DMF was about 20%. The final reacted products were precipitated by ethanol and then dried residual solvent in the vacuum oven at 80 °C for

Table 1 The chemical structure of raw materials for synthesis of PUUEs

Name	Chemical structure
HTBN	
HDI	
DMDC

120 h. The dried PUUEs were pressed at 200 °C to prepare films for testing. The sample compositions were denoted as listed in Table 2.

2.3 Fourier transform infrared spectroscopy (FTIR)

The FTIR spectra of PUUEs were collected by Fourier transformation infrared spectrometer (TENSOR 27, Bruker Co.) using attenuation total reflection (ATR) mode with 32 times of scan and 2 cm⁻¹ of resolution. The GRAMS/AI program (Thermo Galactic Inc.) was used to deconvolution of FTIR spectra peaks. The peak fitting is performed assuming each peak are Gaussian shape at restriction of peak position condition.

2.4 Synchrotron small/wide-angle X-ray scattering (SAXS/WAXS)

The SAXS measurements were carried out at the BL16B beamline in the Shanghai Synchrotron Radiation Facility (SSRF) in China. The X-ray wavenumber was 0.124 nm and a Mar165 CCD detector (2048 × 2048 pixels with a pixel size of 80 μm) was employed to collect the SAXS data. The ox tendon (*D* = 63.6 nm) was used as standard material to calibration the scattering vector.

The WAXS experiment of PUUEs was carried out at 1W1A beamline in Beijing Synchrotron Radiation Facility (BSRF) with 1.5473 Å of wavelength and Mar345 detector. Silver behenate (*d*₀₀₁ = 58.380 Å) was used as standard material to calibrate the scattering angle.

2.5 Thermal analysis

Differential scanning calorimetry (DSC) thermograms were obtained by a Q2000 thermoanalyzer system (TA Corp. USA) with 10 °C min⁻¹ of heating and cooling rate under nitrogen (N₂) of atmosphere. Each samples was weighted about 5–10 mg for DSC measurements.

2.6 Atomic force microscope (AFM)

The surface morphology of PUUEs was observed by a MFP-3D Origin AFM system (Oxford Instruments Co. USA) with tapping mode. The AFM tips (AC240TS-R3, Asylum Research)

with 26 N m⁻¹ spring constant and 300 kHz of resonance frequency were used to measurements.

2.7 Measurements of electric properties

The dielectric constant and dissipation factor of PUUEs were measured by broadband dielectric spectroscopy (Novochtrol GmbH, Germany) at 25 °C. The samples were prepared as circular shape with 10 mm of diameter and about 1 mm of thickness.

The DC breakdown voltages of PUUEs were obtained by HT-50 breakdown voltage tester (Guilin Electrical Equipment Scientific Research Institute Co., Ltd., China) in the silicon oil bath at room temperature. Each sample was measured five times and then took average value. The breakdown voltage strength were calculated based on DC breakdown voltage.

The DC volume resistance of PUUEs were measured by ZC36 high resistance meter (Shanghai sixth meter factory, China) at room temperature. The effective contact part between each sample and electrode is a circular shape with 50 mm of diameter. The DC volume resistivity of samples were obtained according to the formula $R = \rho \frac{L}{S}$, where *R*, *ρ*, *L* and *S* represent volume resistance, volume resistivity, thickness of samples and the effective contact area between each sample and electrode.

2.8 Mechanical properties testing

Tensile testing of PUUEs were completed by a universal testing machine (Instron 3366, Instron Cor. USA) with 20 mm min⁻¹ of stretching rate at 25 °C. The samples were prepared by cutting dumbbell tensile specimens. The length of narrow parallel portion is 12 mm, the width of narrow parallel portion is 2 mm, and the thickness is 1 mm. The shore hardness of PUUEs were measured by Shore durometer (XY-1, Shanghai chemical machinery, China) and the thickness of each sample is about 10 mm. For the mechanical property testing, each sample was measured for at least 5 times and then took average value.

2.9 Electromechanical property

Actuation strain measurements were performed by using circular membrane actuators in the air, in which the dielectric elastomer films were placed between two circular frames

Table 2 Compositions of PUUEs

Sample	Molar ratio of <i>n</i> _{NCO} / <i>n</i> _{OH} / <i>n</i> _{NH₂} ^a	Hard segment content calculated by feed composition, <i>f</i> _{HS} ^b (wt%)	Hard segment content measured by TGA ^c (%)	Molar ratio of urea and urethane, <i>R</i> _{UA/UT} ^d	Weight fraction of C≡N, <i>f</i> _{CN} ^e (wt%)
PUU-HS-13	1.78/1/0.78	12.5	14	0.69	12.2
PUU-HS-26	3.56/1/2.56	26.4	26	2.39	10.2
PUU-HS-39	5.84/1/4.84	38.9	38	4.56	8.5
PUU-HS-50	8.89/1/7.89	50.2	45	7.47	6.9

^a *n*_{NCO}, *n*_{OH} and *n*_{NH₂} are the mole numbers of NCO groups from HDI, OH groups from HTBN and NH₂ groups from DMDC, respectively.

^b $f_{HS} = \frac{m_{HDI} + m_{DMDC}}{m_{HTBN} + m_{HDI} + m_{DMDC}} \times 100\%$, where *f*_{HS} is weight fraction of hard segment in PUUEs, and *m*_{HDI}, *m*_{DMDC} and *m*_{HTBN} are the weights of HDI, DMDC and HTBN, respectively. ^c The TGA data can be found in ESI (Fig. S1). ^d $R_{UA/UT} = n_{NH_2}/n_{OH}$, where the *R*_{UA/UT} is molar ratio of urea and urethane. ^e $f_{CN} = 13.9\% \times (1 - f_{HS})$, *f*_{CN} is weight fraction of C≡N in PUUEs.

without any pre-strains. The strain was defined as the change of the electrodes' area divided by the original area. Electric field from 0 kV mm^{-1} were loaded on the electrode area until electric breakdown occurred. During actuation, the video images of the biaxial extension of the electrode area were captured by a camera fitted with a wide-angle lens, and then the captured video images were processed with Adobe Photoshop software. The sample thickness were about 0.1 to 0.2 mm, and the compliant electrode coated diameter was 5 cm. The compliant electrode was prepared by combination of graphite, silicone oil, and curing agent.²⁵

3. Results and discussion

3.1 Structure and morphology of PUUEs

In the first step polymerization process, the excess HDI and HTBN react to form diisocyanate terminated HDI-HTBN multiblock copolymer, and then further react with chain extender (DMDC) to form poly(urethane-urea) copolymer in the second step. The ratio of UT and UA can be calculated the feed molar ratio of OH from HTBN and NH_2 from DMDC as shown in Table 2. The length of HS and the content of UA groups in HSs is increased with increase of HS content. If the ratio of NCO/OH is high at the first step, the excess diisocyanate should be existed. And, the excess diisocyanate should be preferentially reacted with chain extender to form amine terminated longer urea chains. The formed urea chains can further react with polyurethane oligomer to form polyurethane-urea copolymer at later state. Fig. 1 shows the schematic chain structure of the PUUEs fabricated by HTBN, HDI and DMDC. The PUUEs are containing urea (UA) and urethane (UT) units in the HS. The UA groups only exist in the interior of hard segments, the UT groups,

however, exist mainly on the boundaries between HS and SS as shown in Fig. 1.

The chemical structures of PUUEs were characterized by FTIR as shown in Fig. 2. We can observe the N-H stretching mode at the region of $3500\text{--}3200 \text{ cm}^{-1}$, the C=O stretching mode at the region of $1780\text{--}1600 \text{ cm}^{-1}$, the C≡N stretching mode at 2238 cm^{-1} , and the amide II at the region of $1560\text{--}1480 \text{ cm}^{-1}$. However, the absorbance band of NCO group is not detected at 2274 cm^{-1} , indicating the NCO groups are absence in the PUUEs.²⁶ In addition, the CH_2 vibration bands (in the $2900\text{--}2800 \text{ cm}^{-1}$ and $1500\text{--}1300 \text{ cm}^{-1}$ regions) are almost independent on HS content as shown in Fig. 1(a). It means that the conformation of HDI residuals in HS is almost independent on HS content. Whereas, the stretching vibration bands of C=O ($1760\text{--}1600 \text{ cm}^{-1}$) of PUUE are sensitive to the HS content. The peaks of C=O are contributed from UA and UT units. The hydrogen behaviors of HS can be determined by C=O bands. Based on free and hydrogen bonded (H-bonded) C=O bands,^{27,28} the C=O region can be fitted into five separated peaks of 1723 , 1703 , 1685 , 1668 and 1636 cm^{-1} , as shown in Fig. 2(b). The assignments of those peaks are listed in Table 3.

The bands at 1723 and 1703 cm^{-1} are assigned to free and H-bonded C=O groups from UT units,²⁹ and the bands at 1683 , 1663 and 1632 cm^{-1} are assigned to free, disordered and ordered hydrogen bonding of C=O from UA units,^{28,30,31} for the UA unit in PUU, Luo *et al.*²⁸ assigned the band at 1668 cm^{-1} to disordered hydrogen bonding of C=O from urea, and the band at 1636 cm^{-1} to ordered hydrogen bonding C=O from urea. The disordered urea hydrogen bonds (1666 cm^{-1}) had the property of short range ordering. The disordered band did not associate with crystallites in the hard domain at all. Marcos-Fernández *et al.*³² reported that the band at 1640 cm^{-1} was assigned to "internal" urea groups of the chains (*i.e.*, ordered).

Fig. 1 Schematically drawn the synthesis steps and chain structure of PUUEs using HDI, DMDC, and HTBN. HS: hard segment, SS: soft segment, HTBN: hydroxyl-terminated polybutadiene-acrylonitrile copolymer, HDI: hexamethylene diisocyanate, and DMDC: 3,3'-dimethyl-4,4'-diamino dicyclohexyl methane.

Fig. 2 FTIR spectra of PUUEs displayed in various wavenumber ranges (a) 4000–500 cm^{-1} , and (b) 1760–1600 cm^{-1} .

Table 3 Infrared band assignments

Wavenumber (cm^{-1})	Band assignment
1723	Free C=O from urethane
1703	Hydrogen-bonded urethane C=O
1683	Free C=O from urea
1663	Hydrogen-bonded, disordered, urea C=O
1632	Hydrogen-bonded, ordered, urea C=O

The band at 1666 cm^{-1} was relative to contributions from “isolated” urea groups and hydrogen-bonded with ether groups (*i.e.*, disordered).

The hydrogen bonding between HSs is major driving force to form HD structure. In the case of HTBN-based PUUEs, the hydrogen bonding between C=O and N-H groups may exist between UA and UA groups (UA-UA), or between UA and UT groups (UA-UT) or between UT and UT groups (UT-UT). The relative fraction of certain C=O band was calculated by the ratio of certain C=O absorbance and total C=O bands

absorbance assuming C=O peaks (free and hydrogen bonded UA and UT bands) absorption coefficients are same. For example, the relative intensity of band at 1723 cm^{-1} was calculated by $f_{1723} = \frac{A_{1723}}{A_{1723} + A_{1703} + A_{1683} + A_{1663} + A_{1632}}$, where A_{1723} , A_{1703} , A_{1683} , A_{1663} and A_{1632} were absorbance of bands at 1723, 1703, 1683, 1663 and 1632 cm^{-1} , respectively. Since the free or hydrogen bonded C=O groups came from both UT and UA units, the fraction of free and hydrogen bonded C=O were calculated by $f_{\text{free}} = \frac{A_{1723} + A_{1683}}{A_{1723} + A_{1703} + A_{1683} + A_{1663} + A_{1632}}$ and $f_{\text{H-bonded}} = \frac{A_{1703} + A_{1663} + A_{1632}}{A_{1723} + A_{1703} + A_{1683} + A_{1663} + A_{1632}}$, respectively. The calculated relative fraction of each C=O band, free and H-bonded C=O bands are showed in Fig. 3.

The relative fraction of H-bonded C=O from UT (1703 cm^{-1}) is decreased with increase of HS content, whereas the disordered and ordered H-bonded C=O from UA (1663 and 1632 cm^{-1}) are increased as shown in Fig. 3(a). It indicates that the H-bonding between UA and UA units are dominated as increase of HS content. On the other hand, the relative fractions of free and ordered H-bonding C=O are almost monotonically decreased and increased with increase of HS content, respectively, as shown in Fig. 3(b). For example, the relative fraction of free C=O in HS is decreased from 31% to 9% (decreased about

Fig. 3 Hard segment content dependent relative fractions of (a) each C=O bands, (b) free and H-bonded C=O in poly(urethane-urea) elastomers.

70%) when the HS content increased from 12.5% to 50.2%. The fraction of hydrogen bonded C=O can somewhat reflect the degree of microphase separation because the HD formed by hydrogen bonding between HSSs. However, Runt *et al.*³³ argued the FTIR method is insensitive the morphology change of secondary hard domain coalescence.

In our case, the hydrogen bonding behaviors of UA and UT units indicated that the hydrogen bonded UA units significantly increased when increase of HS content due to increase of sequence length of HSSs. The WAXS data indicated that the crystal structure is changed when the HS% above 39% as shown in Fig. 4. For example, the PUU-HS-13 and PUU-HS-26 samples show a weak diffraction peak at 20.8° (4.29 Å), and the PUU-HS-39 and PUU-HS-50 samples show a weak diffraction peak at around 9.6° (9.25 Å). It means that the crystal structure formed by short length of HSSs is different with that by longer length of HS. The detail crystal structure need to further study.

On the other hand, the DSC thermograms of PUUEs (Fig. 5) show a weak transition at around 175 °C and obvious endothermic peak at around 220 °C. We considered that the transition temperature at 175 °C is due to order–disorder transition (ODT), and the endothermic peak at 220 °C is due to melting of PUUEs crystals. Logically, the HS crystalline phase is more stable than HD, so the melting temperature of HS crystal should be higher than ODT. The ODT of PUU-HS-39 and PUU-HS-50 showed higher than that of PUU-HS-13 and PUU-HS-26. The DSC results indicated that the ODT and melting temperature of PUUEs are slightly improved by increase of HS%. The glass transition temperature of soft domain (SD) in PUUEs are also observed at around −42 °C by DSC. It is indicated that the T_g of SS is almost independent on HS. It reflects that the degree of microphase separation is almost independent on HS content.

The microstructure of PUUEs is characterized by SAXS as shown in Fig. 6. A scattering peak appeared at 0.0198, 0.01448 and 0.0084 Å^{−1} for PUU-HS-12, PUU-HS-26, and PUU-HS-39 samples. However, we cannot observed scattering peak in the PUU-HS-50 sample. It is owing to limited the SAXS

Fig. 4 WAXS profiles of PUUEs with various hard segment content.

Fig. 5 DSC thermograms of PUUEs obtained during the second heating process with 10 °C min^{−1} of heating rate.

Fig. 6 SAXS profiles of PUUEs with various hard segment content.

measurement range. Nevertheless, we can found that the scattering peak shift to low scattering vector, q , as increase of HS content, and the peak become to more shape. The scattering peak in SAXS patterns is caused by electron density difference between two phases. In our case, the PUUEs have three phases including HS crystalline phase, HD and SD domain phases. In addition, the HS crystalline phase should be coexist with HD phase or is individually existed. In the view of electron density, the electron density of HS crystalline phase and HD are similar which is higher than that of SD. Therefore, the Lorentz-corrected 1D SAXS data can provide an information of the average distance between HD (or HS crystal phase) and SD along one-direction. Accordingly, the long distance calculated by $L = \frac{2\pi}{q_{\max}}$ (where $q_{\max}$ is the q value at maximum intensity of scattering peak) is corresponding to the sum of thickness of HD

and SD.³⁴ The corresponding long distance of PUU-HS-12, PUU-HS-26, and PUU-HS-39 is 31.6, 43.4 and 74.8 nm, respectively. If increase the HS%, the sequence length of HS is increased, results in increase of the thickness of HD.

The morphology of PUUEs were observed by AFM as shown in Fig. 7. The AFM phase image is sensitive to the mechanical property difference between phases, therefore can be used to determine the phase distribution and size. In our case, the phase contrast of AFM images may come the modulus difference between crystalline phase (with or without HD) and other phases. In our case, the deep color (lower phase angle) regions in AFM phase images can be assigned to crystalline phase due to repulsive force caused lower phase angle. As shown in Fig. 7, the crystalline phase size of PUUEs have about hundred nanometer of size, and the size is become to be larger when increase HS content above 39%. The numbers of crystalline phase also increased with increase of HS%. The SAXS and AFM results indicated that the crystalline phase thickness and size are significantly become to larger with increase of HS content.

3.2 Mechanical properties of PUUEs

The strain–stress curves of PUUEs showed in Fig. 8. The mechanical property of break tensile strength, Young's modulus, break elongation and Shore hardness were summarized in Table 4. Among the PUUEs, the PUU-HS-13 sample showed 0.7 MPa of Young's modulus and 681% of break elongation. The Young's modulus and Shore hardness were improved about 8000% and 64%, respectively, when the HS content increased from 12.5 to 50.2%. When increase of HS%, the size and numbers of HD (including HS crystalline phase) significantly increased as results in enhance the mechanical stability of physical cross-linked networks.

3.3 Dielectric properties of PUUEs

In order to understand the structure and dielectric property relationship of PUUEs, the dielectric constant and dielectric

Fig. 8 The strain–stress curves of PUUEs with various hard segment content.

loss were measured as shown in Fig. 9 and 10. The dielectric constant of PUUEs are almost independent on frequency in the region of 10–10⁶ Hz, however, the dielectric constants of PUUEs are significantly influenced by the HS content as shown in Fig. 9. We unexpectedly found that the dielectric constant of PUUEs at 1 kHz are almost linearly decreased with increase of HS content as shown in Fig. 11. For example, the dielectric constant of PUUEs is decreased from 7.2 to 4.1 when the hard segment content increased from 12.5 to 50.2% at 1 kHz. It means that HD with high degree of H-bonded C=O and large size is unfavorable for improvement the dielectric constant. Increase of degree of H-bonded C=O and the size of HD may reduce the excess dipole polarizations of HDs. The HTBN-based PUUEs are showed lower dielectric constant than HDI–HTBN–butylene glycol (BDO) based PU¹⁷ at similar HS content. However, the dissipation factors of PUUEs are almost

Fig. 7 AFM phase images of HTBN-based PUUEs with various hard HS content. (A) 12.5%, (B) 26.4%, (C) 38.9%, (D) 50.2%.

Table 4 Mechanical properties of PUUEs with various hard segment content

Sample	Break tensile strength (MPa)	Break elongation (%)	Young's modulus (MPa)	Hardness (Shore A)
PUU-HS-13	2.1 ± 0.1	681 ± 52	0.7 ± 0.1	60.5 ± 1.5
PUU-HS-26	4.2 ± 0.2	540 ± 19	1.5 ± 0.2	73.0 ± 0.8
PUU-HS-39	7.5 ± 0.6	285 ± 21	4.8 ± 0.6	86.8 ± 1.7
PUU-HS-50	22.8 ± 0.7	235 ± 14	56.8 ± 3.0	99.3 ± 0.5

Fig. 9 The frequency dependent dielectric constant of PUUEs with various hard segment content.

independent in the hard segment content as shown in Fig. 10. All PUUEs are showed about 0.018 of dissipation factor in the frequency region of 10^2 to 10^5 Hz.

As we known, five types of polarization can exist in polymers, namely, electronic, atomic, dipole orientational, ionic, and interfacial polarization.^{35–38} Electronic and atomic polarizations originate from electron cloud and skeletal atom movements deviated away from the equilibrium position as induced by an

Fig. 10 The frequency dependent dielectric dissipation factor ($\tan \delta$) of PUUEs with various hard segment content.

external field, and thus they occur at very high frequencies, *i.e.*, in the infrared and optical range. These two types of polarization exist in all polymers, no matter if they are polar or nonpolar, amorphous or crystalline. If a polymer is polar and contains permanent dipoles, these permanent dipoles may respond to the external field by rotation, resulting in orientational polarization in the polymer. If a polymer contains ionic species, either impurity ions or ions in polymer electrolytes and polyelectrolytes, ionic polarization occurs below a few hundred Hz. Finally, for a multicomponent polymer system, interfacial polarization takes place due to interfaces caused the Maxwell–Wagner effect.^{36,37} The relaxation of these interfacial charges may take from seconds to hours or even years (*e.g.*, charges trapped in polymer electrets).³⁹ In the previous work,^{17,18} we demonstrated that the HTBN based PUs have good dielectric performance than others PUs, and we found that the concepts of local polarization from free hydrogen bonded polar groups of hard domain are major factor to enhancing the dielectric constant. The polarization mechanism of dipole orientation and interface in multi-phases polymer systems is very complex. The PUUEs has three phases including SD, HD and HS crystalline phase. If increase the HS%, the size and numbers of HD (including HS crystalline phase) are enhanced, results in mobility of SS are constrained by enhanced physical cross-linking. In addition, the contributions of HD on dielectric constant should be reduced as increase of degree of hydrogen bonding in HDs due to reduce of local polarization. The dielectric constant of PUUEs showed flat line in the frequency region of 10 – 10^6 Hz. The main reason can be explained that the

Fig. 11 Hard segment content dependent dielectric constant, breakdown strength and Young's modulus of PUUEs.

Table 5 Electric properties of PUUEs

Sample	Volume resistivity (Ω cm)	Dielectric constant at 1 kHz	Breakdown strength (kV mm^{-1})
PUU-HS-13	5.05×10^{12}	7.2	29.3 ± 0.7
PUU-HS-26	7.11×10^{12}	6.3	47.9 ± 1.9
PUU-HS-39	3.25×10^{13}	5.1	61.0 ± 3.5
PUU-HS-50	4.11×10^{13}	4.1	89.6 ± 5.9

SSs are constrained by cross-linked network results in reduce the mobility.

The breakdown strength of PUU is also increased from 29.3 to 89.6 kV mm^{-1} (increased about 206%) when the HS content increased from 12.6 to 50.2% as shown in Fig. 11. The PUU-HS-50 sample is showed 89.6 kV mm^{-1} of breakdown strength which is higher than general rubber materials, such as NBR,²⁵ natural rubber⁴⁰ and SEBS.⁴¹ The volume resistivity of PUUEs were also measured as shown in Table 5. The volume resistivity of PUEs showed above $10^{12} \Omega$ cm of value, and is increased with increase of HS content. The volume resistivity of PUUE is increased about 700% when the HS content increased from 12.6 to 50.2%. It is well known the mechanism of breakdown is a complex phenomenon. The basic mechanisms of breakdown involve intrinsic breakdown, thermal breakdown, and avalanche breakdown *etc.*⁴² The resistivity and Young's modulus are significantly enhanced as increase of HS%, whereas the onset degradation temperature is almost independent on HS%. Accordingly, we suggested that improving the electric insulation and mechanical stability of PUUEs are effective ways to improve the breakdown strength.

Even through both dielectric constant and breakdown strength of PUUEs are strongly dependent on HS content, the dielectric constant and breakdown strength are showed opposite trend as shown in Fig. 11. In addition, the HS% dependent breakdown strength and modulus showed different behaviors. In the case of PUUEs, as increase of HS%, the increasing rate of breakdown strength showed fast than that of modulus. It indicates that the breakdown strength is more sensitive to the HS content.

In the practical application view, the mechanical property, dielectric constant and breakdown strength of PUUE should be optimized. Because the actuation strain of DE is proportional to its dielectric constant and breakdown strength and inversely proportional to its elastic modulus.

3.4 Hard segment content dependent electromechanical property of PUEs

In order to understand the effect of HS content on the electro-mechanical property of PUUEs, we observed the actuation area strain of HTBN-based polyurethane elastomers as shown in Fig. 12. The actuation area stain of PUUEs is significantly increased with increase of electric field, and is decreased with increase of HS content at a certain electric field as showed in Fig. 12. It is owing to the electromechanical sensitivity β (the

Fig. 12 Dependence of actuation area strain of HTBN-based polyurethane elastomers on electric field.

ratio of dielectric constant and Young's modulus)²⁵ of PUUEs is significantly decreased with increase of HS content. Specifically, the PUU-HS-13 sample showed best actuation strain at lower electric field in among the PUUEs. And, the maximum actuation area strain of PUU-HS-26 sample can be reached about 26% at without pre-stretching. Based on combination of dielectric property and mechanical property, we considered that PUU-HS-26 sample may more suit for artificial muscles with larger actuation strain or energy storage applications. On the other hand, PUU-HS-39 and PUU-HS-50 samples showed linear relation between actuation strain and electric field in contrast with PUU-HS-13 and PUU-HS-26 samples, which is useful for linear actuator applications. It indicates that the electric field dependent actuation strain behaviors of PUUs can be controlled by HS content.

4. Conclusions

In this work, we synthesized novel dielectric PUUEs using HDI and DMDC as HS and HTBN as soft segment. The crystallinity, long period and HD sizes of PUUEs were strongly dependent on the HS content. The PUUE with 12.5% of HS content showed 7.2 of dielectric constant at 1 kHz and 29.3 kV mm^{-1} of breakdown strength. However, the dielectric constant of PUUEs was significantly decreased with increase of HS content, whereas the breakdown strength and Young's modulus of PUUEs were significantly increased. The dissipation factor of PUUEs, however, were almost independent on HS content, and showed about 0.018 of dissipation factor in the frequency region of 10^2 to 10^5 Hz. Specifically, the PUU with 50% of HS content showed 89.6 kV mm^{-1} of breakdown strength which is more higher than general PUEs PUUEs. The PUUEs with various HS content showed different actuation strain behaviors. We found that resistivity and Young's modulus are significantly enhanced as increase of HS%, whereas the onset degradation temperature is almost independent on HS%. And, the dielectric constant of PUUEs are significantly influenced by the dipole orientation

polarization of local polar groups in HD and cross-linked network structure confined SSs. Our results indicated that the dielectric and mechanical properties of PUUEs can be optimized by controlling of HD structure.

Conflicts of interest

There are no conflicts to declare.

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